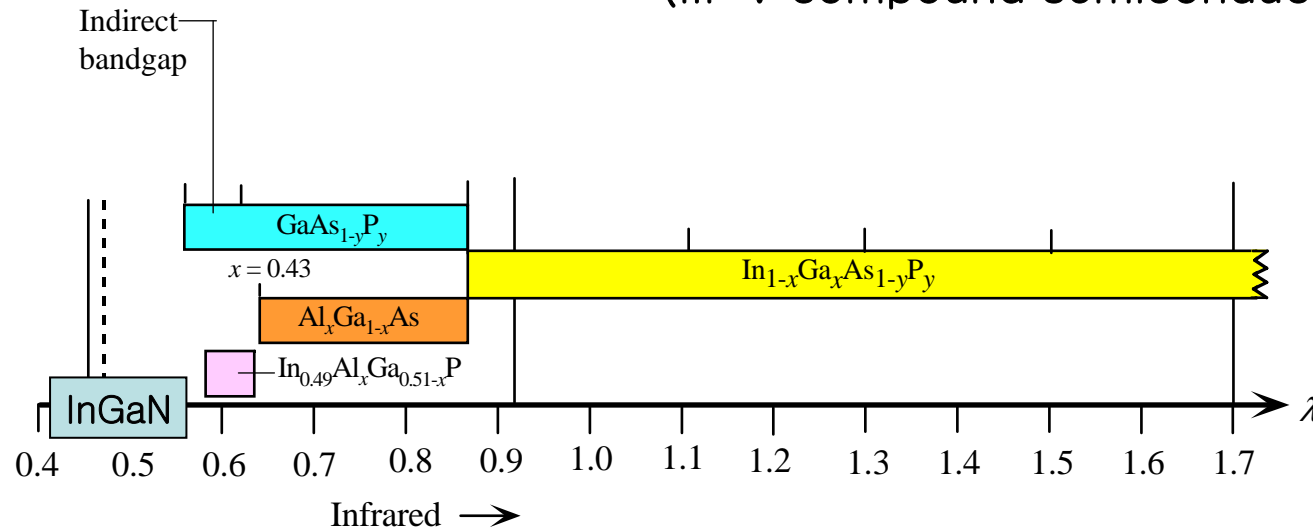


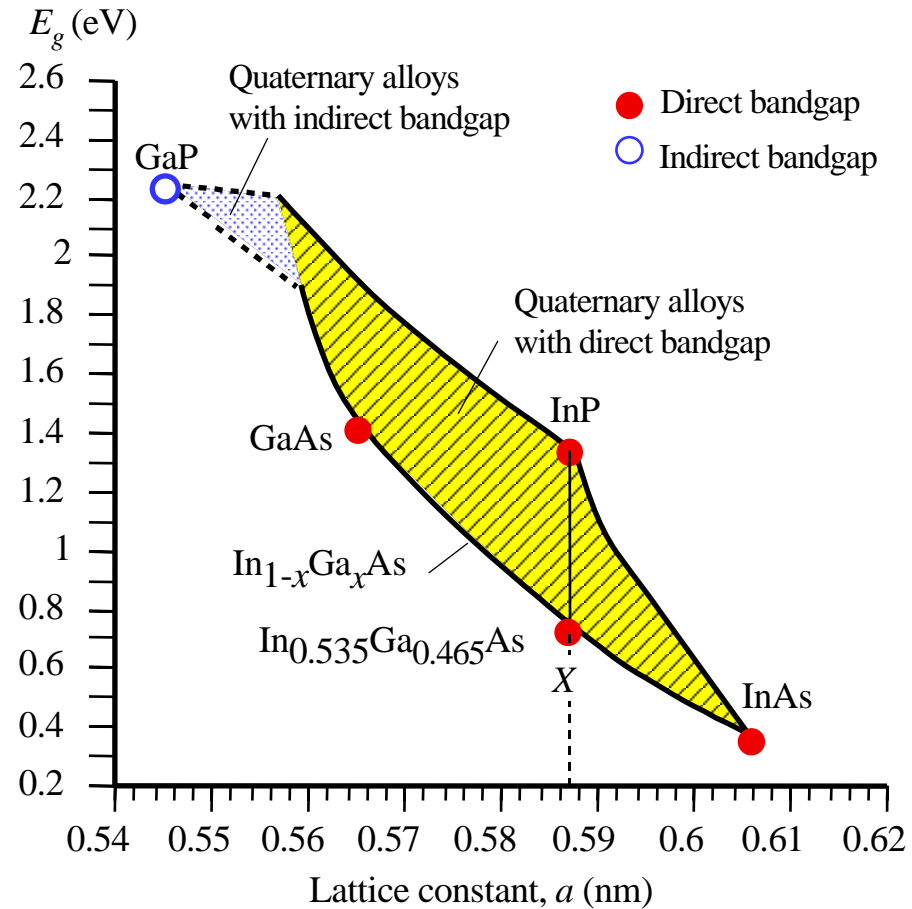
Lect. 20: Semiconductor Laser

- Semiconductors lasers are small, cheap and very efficient.
- Wavelength: Bandgap of direct semiconductor materials (III-V compound semiconductors)



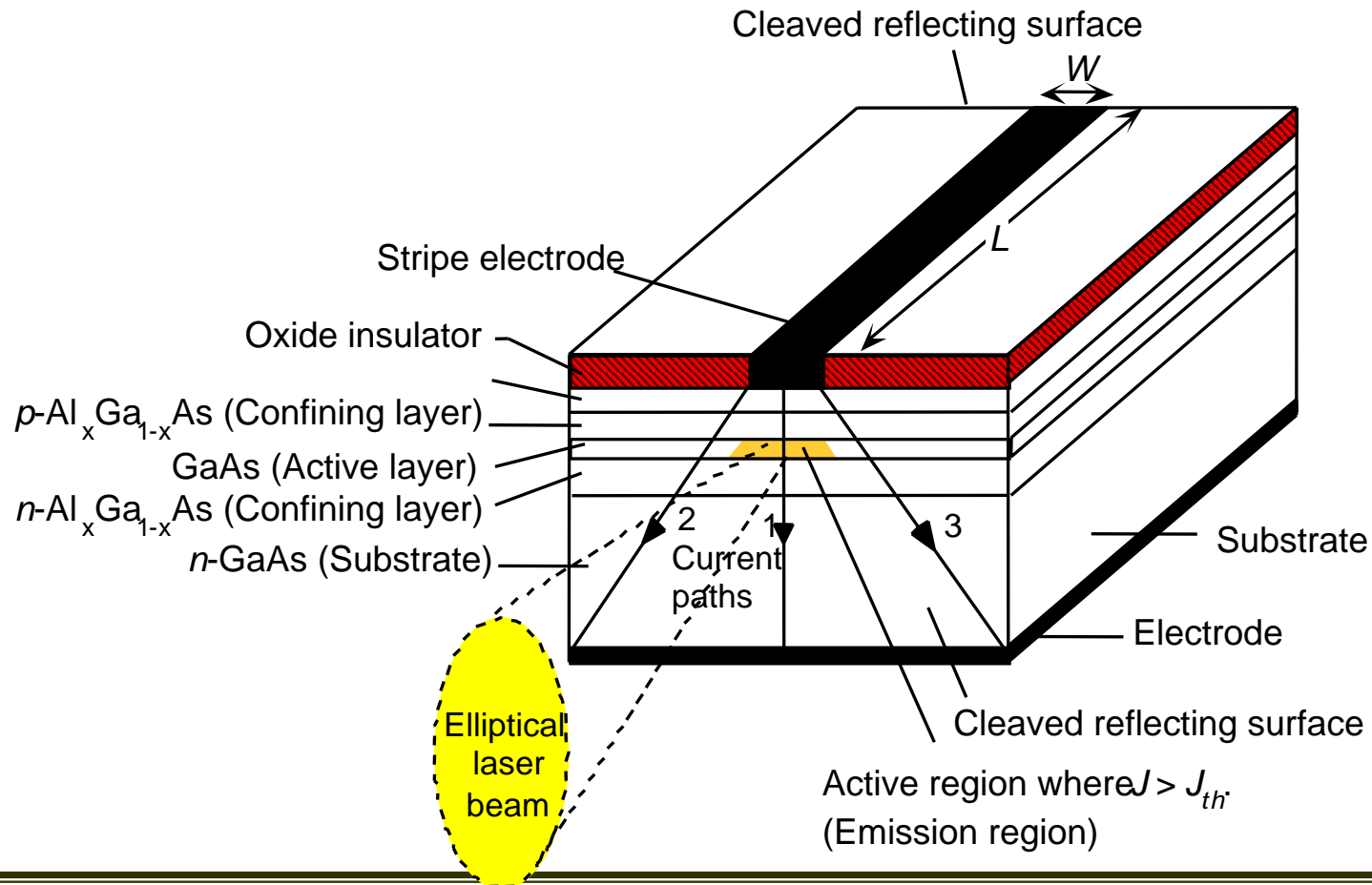
	13/IIIA	14/IVA	15/VA
	5 B 10.81	6 C 12.01	7 N 14.01
B	13 Al 26.98	14 Si 28.09	15 P 30.97
	31 Ga 69.72	32 Ge 72.61	33 As 74.92
	49 In 114.8	50 Sn 118.7	51 Sb 121.8

Lect. 20: Semiconductor Laser



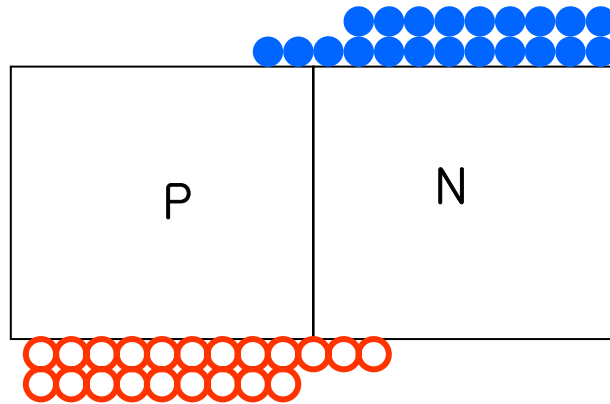
Lect. 20: Semiconductor Laser

Semiconductor Laser Structure: PN Junction + Mirror (Cleaved Facets)

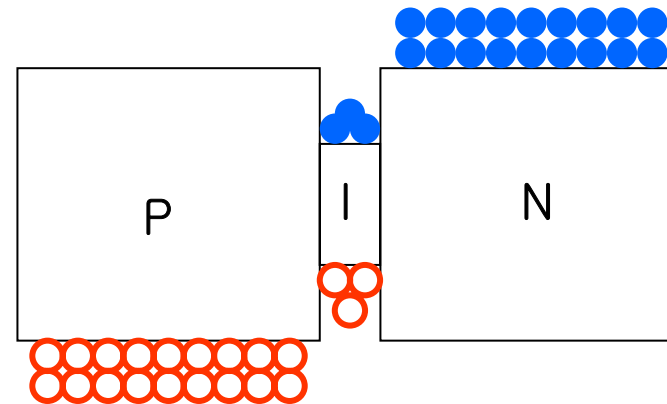


Lect. 20: Semiconductor Laser

Efficient carrier confinement: PIN structure with large E_g for P, N regions



Injected carriers are spread-out
=> smaller density

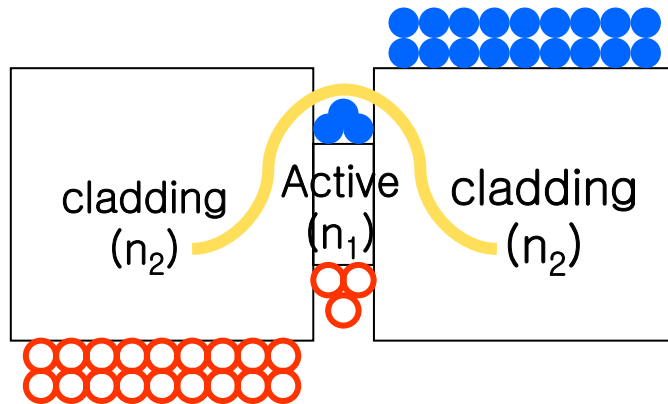


Double heterojunction: Confinement of
Injected carriers
=> larger density

For population inversion,
$$\frac{N_2 \cdot P_1}{N_1 \cdot P_2} > 1$$

Lect. 20: Semiconductor Laser

Efficient photon confinement: PIN structure with smaller n for P, N regions



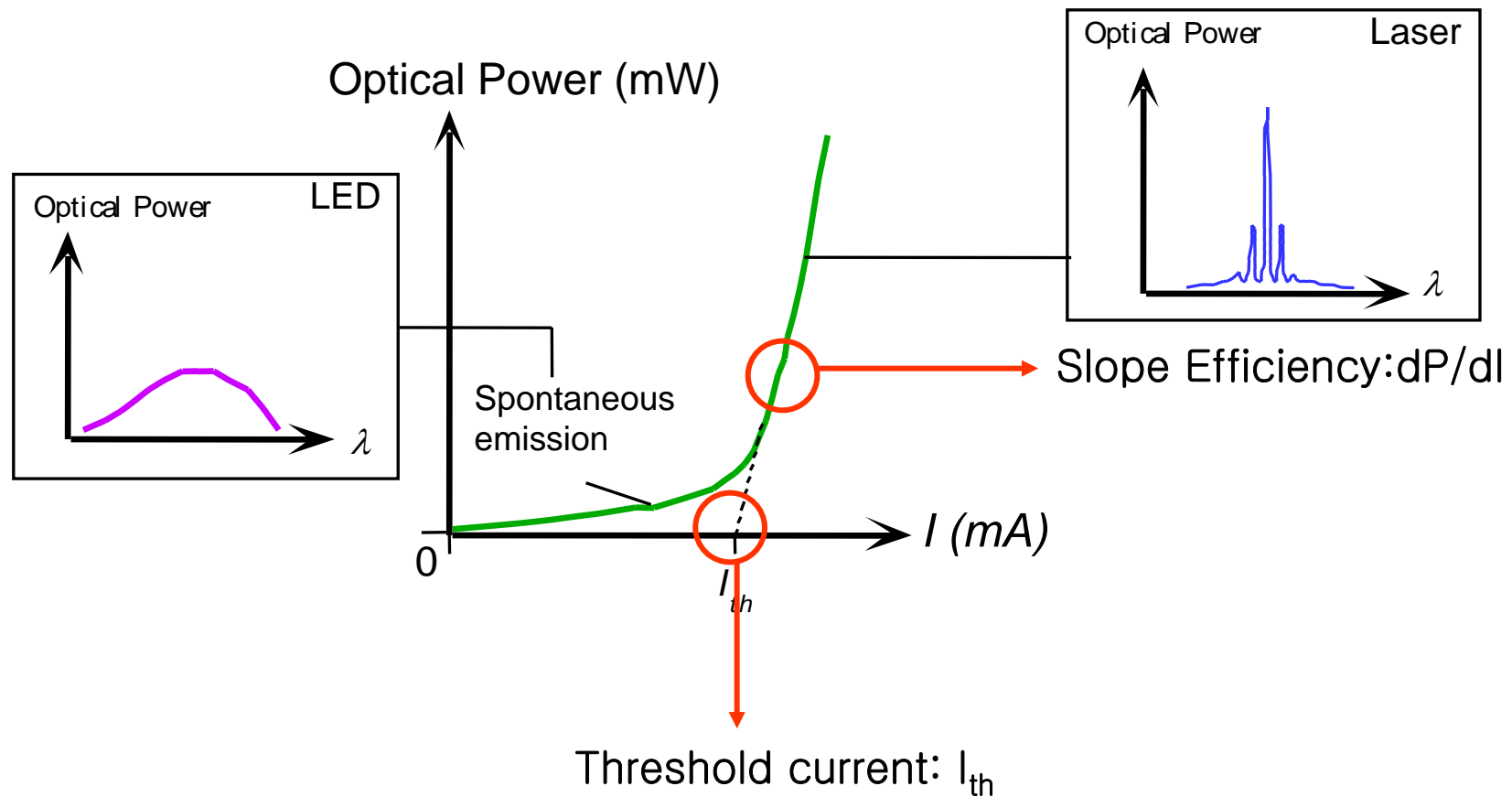
Smaller E_g material has larger n
($n_1 > n_2$)

=> more photons in the active region
and larger Γ

With $\Gamma < 1$

$$g_{\text{th}} = \frac{1}{L} \ln \frac{1}{R} \Rightarrow \Gamma g_{\text{th}} = \frac{1}{L} \ln \frac{1}{R} = \alpha_m \text{ (mirror loss)}$$

Lect. 20: Semiconductor Laser



Lect. 20: Semiconductor Laser

Analytical expression for I_{th}

Assume optical gain increases linearly with injected carriers: $g = a(N - N_0)$

- Carrier density required for lasing (N_{th}):

$$\text{Since } g_{th} = \frac{\alpha_m}{\Gamma}, \quad N_{th} = \frac{g_{th}}{a} + N_0 = \frac{\alpha_m}{\Gamma a} + N_0$$

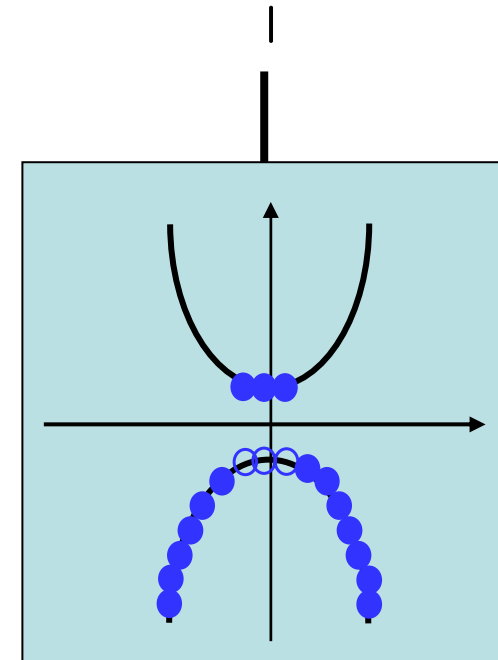
- Relationship between N and I

$$\frac{dN}{dt} = \frac{I}{qV} - \frac{N}{\tau};$$

(V : volume of active region, τ : carrier life time)

$$\text{In steady-state, } I = \frac{N}{\tau} \cdot qV$$

- Current required for lasing (I_{th}):
$$I_{th} = \frac{N_{th}}{\tau} \cdot qV = \left(\frac{\alpha_m}{\Gamma a} + N_0 \right) \frac{1}{\tau} \cdot qV$$



Lect. 20: Semiconductor Laser

Analytical expression for dP/dI

Assume injected carriers are all converted into photons by stimulated emission when $I > I_{th}$

– Change in photon density with time

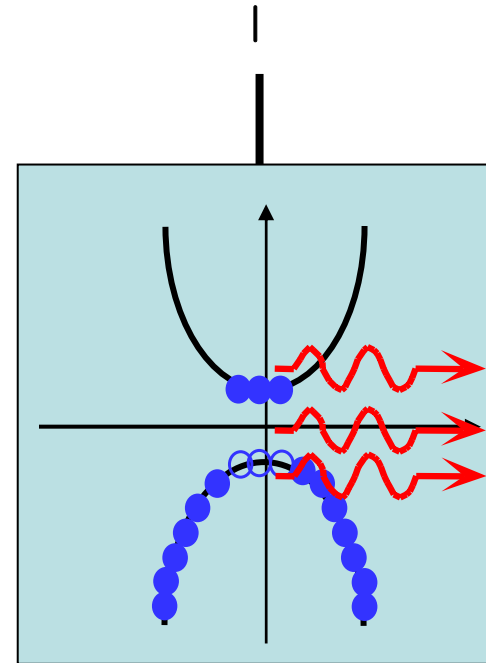
$$\frac{dn_{ph}}{dt} = \frac{I - I_{th}}{qV} - \frac{n_{ph}}{\tau_{ph}}; \quad \tau_{ph} = \frac{1}{v \cdot \alpha_m}$$

– At steady-state,

$$n_{ph} = \frac{I - I_{th}}{qV} \cdot \tau_{ph}$$

– Output power

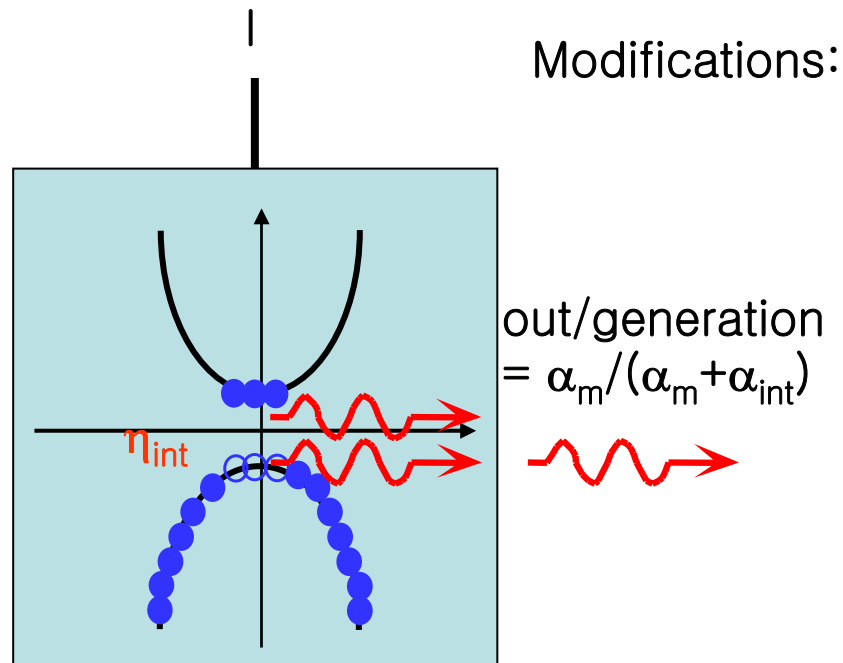
$$P_{out} = \frac{\hbar\omega n_{ph} V}{\tau_{ph}} = \hbar\omega \frac{I - I_{th}}{qV} \cdot \tau_{ph} \frac{V}{\tau_{ph}} = \hbar\omega \frac{I - I_{th}}{q}$$



Lect. 20: Semiconductor Laser

Refinements:

- Injected carriers are not entirely converted into photons: conversion efficiency, η_{int} .
- Photons can be lost internally by impurities, scattering, ... : internal loss, α_{int}



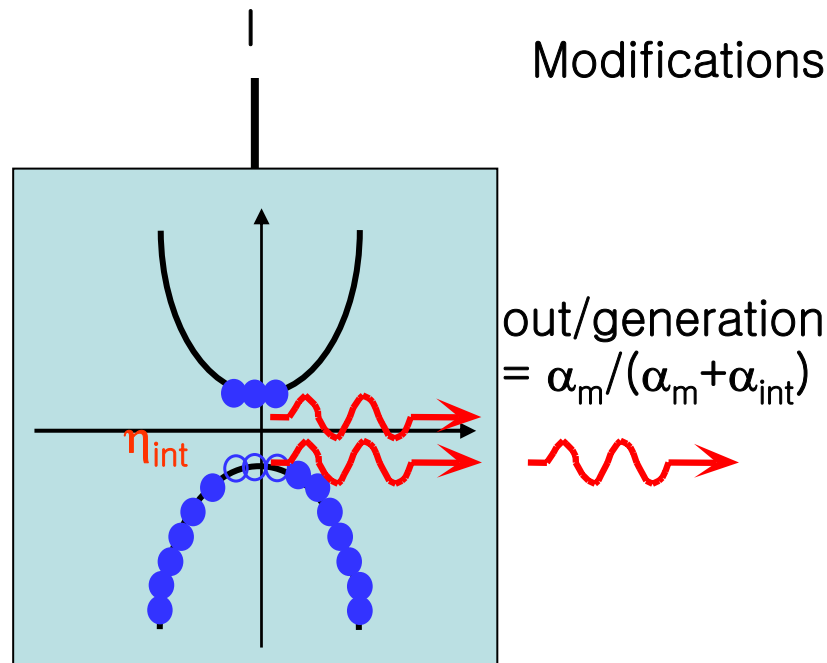
$$g_{th} = \frac{\alpha_m + \alpha_{int}}{\Gamma}$$

$$I_{th} = \left(\frac{\alpha_m + \alpha_{int}}{\Gamma a} + N_0 \right) \frac{1}{\tau} \cdot qV$$

Lect. 20: Semiconductor Laser

Refinements:

- Injected carriers are not entirely converted into photons: conversion efficiency, η_{int} .
- Photons can be lost internally by impurities, scattering, ... : internal loss, α_{int}



Modifications:

$$\tau_{ph} = \frac{1}{v \cdot (\alpha_m + \alpha_{int})} \quad \text{and} \quad \tau_{ph,m} = \frac{1}{v \cdot \alpha_m}$$

$$n_{ph} = \eta_{int} \frac{I - I_{th}}{qV} \cdot \tau_{ph}$$

$$P_{out} = \frac{\hbar\omega n_{ph} V}{\tau_{ph,m}} = \hbar\omega \cdot \left(\eta_{int} \frac{I - I_{th}}{qV} \tau_{ph} \right) \frac{V}{\tau_{ph,m}}$$

$$= \frac{\hbar\omega}{q} \cdot \frac{\tau_{ph}}{\tau_{ph,m}} \cdot \eta_{int} (I - I_{th})$$

$$= \frac{\hbar\omega}{q} \frac{\alpha_m}{\alpha_m + \alpha_{int}} \eta_{int} (I - I_{th})$$

Lect. 20: Semiconductor Laser

